Application No. 10/700,136 Response to Office Action

Customer No. 01933

## Amendments to the Specification

Please amend the paragraph at page 10, line 19 to page 11, line 2 as follows:

A copper bump electrode 10 is formed on the upper surface of a connecting pad portion of each distribution wire 8. On the upper surface of the protective film 5 including and the distribution wires 8, an encapsulating film 11 made of an organic resin such as an epoxy-based resin is formed such that the upper surface of the encapsulating film 11 is leveled with the upper surfaces of the bump electrodes 10. Accordingly, these the upper surfaces of the bump electrodes 10 are exposed. A solder ball 12 is formed on the upper surface of each bump electrode 10.